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JPA
4/30/03

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q58614

Kenichiro SATO, et al.

Appln. No.: 09/541,597

Confirmation No.: 4840

Group Art Unit: 1752

Filed: April 03, 2000

Examiner: R. ASHTON

For: POSITIVE PHOTORESIST COMPOSITION FOR FAR ULTRAVIOLET
EXPOSURE

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APR 22 2003
TC 1700

Reply Filed With RCE

BOX RCE

Commissioner for Patents
Washington, D.C. 20231

Sir:

This Reply is submitted concurrently with a request for continued Examination (RCE) (with a request for suspension of action 37 C.F.R. § 1.103(c) for a period of 3 months) and a petition for extension of time.

REMARKS

First of all, Applicants have received a Notice Regarding Nonpublication Request, dated March 31, 2003, which states that Applicants filed a request for nonpublication on May 21, 2002. However, Applicants did not file, on May 21, 2002 or any other date, a request for nonpublication.

In response to the Request for Reconsideration filed November 18, 2002 and the executed Declaration filed November 22, 2002, the Examiner issued an Advisory